

# 50 YEARS ANNIVERSARY OF STARTING THE IN SITU UHV TEM STUDIES OF THIN FILM GROWTH IN BUDAPEST

*Plenary lecture*

*Dedicated to the memory of late Professor J.F. Pócza on  
the occasion of the 100 years anniversary of his birthday*

**Árpád Barna, Péter B. Barna, György Radnócz**

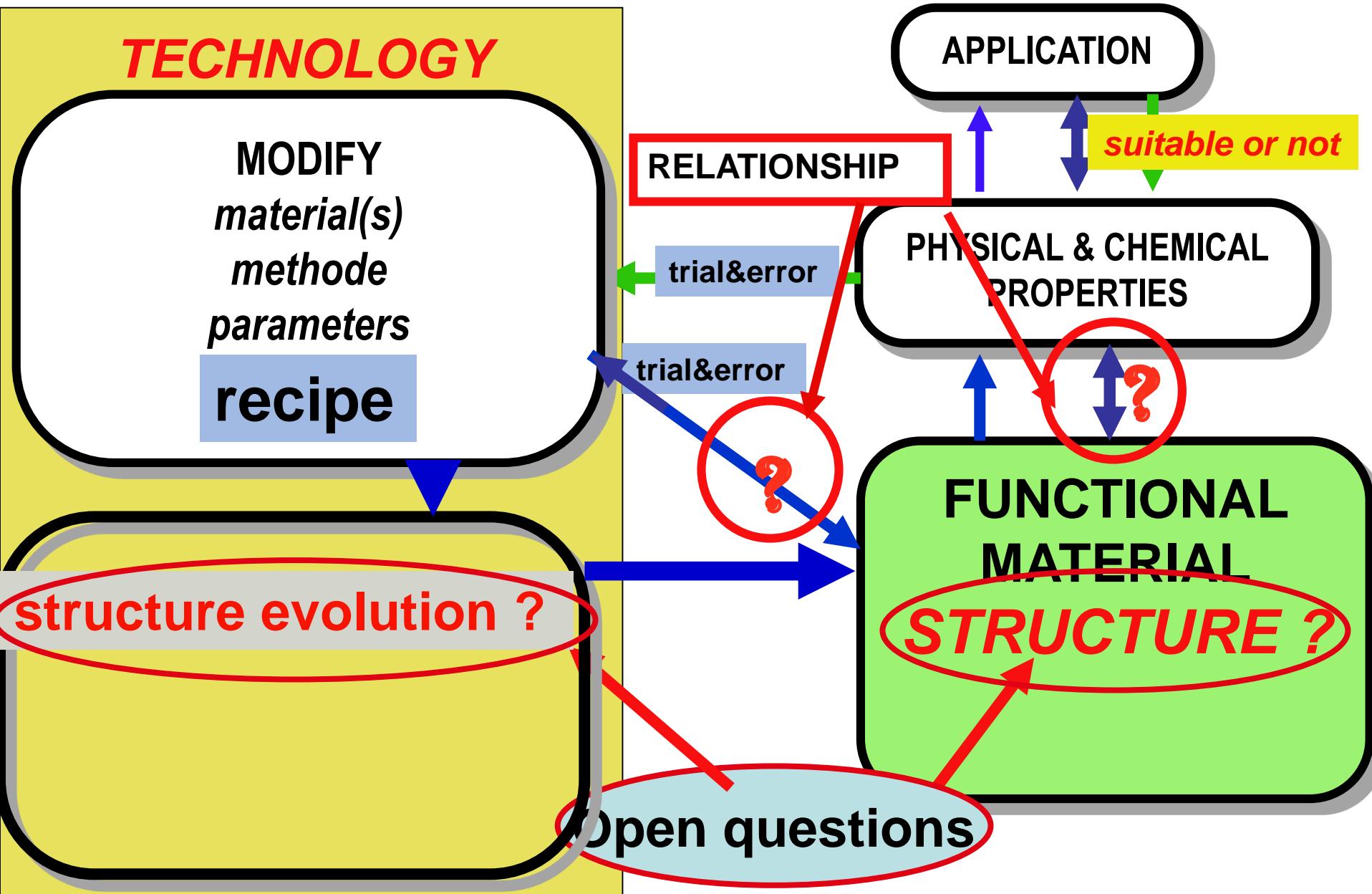
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Centre for Energy Research, Hungarian Academy of Sciences,  
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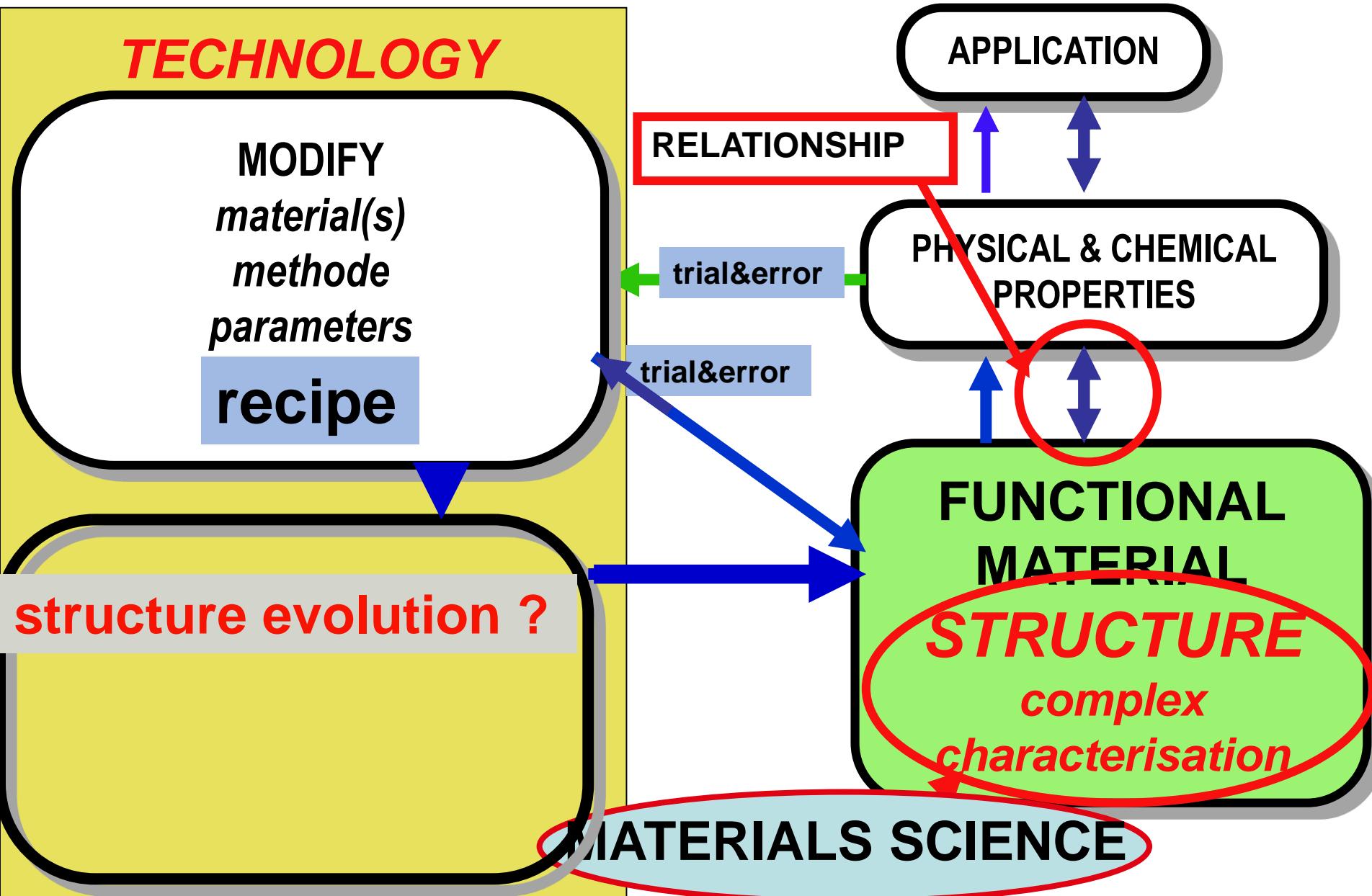
# People dealing with functional materials were greatly excited in the middle of 20th century

- commercialization of materials structure investigation methods and devices (*X-ray diffraction, electron microscopy.....*) provided the possibility to characterize the materials structure at submicroscopic (nm) level (opening the golden age of materials science)

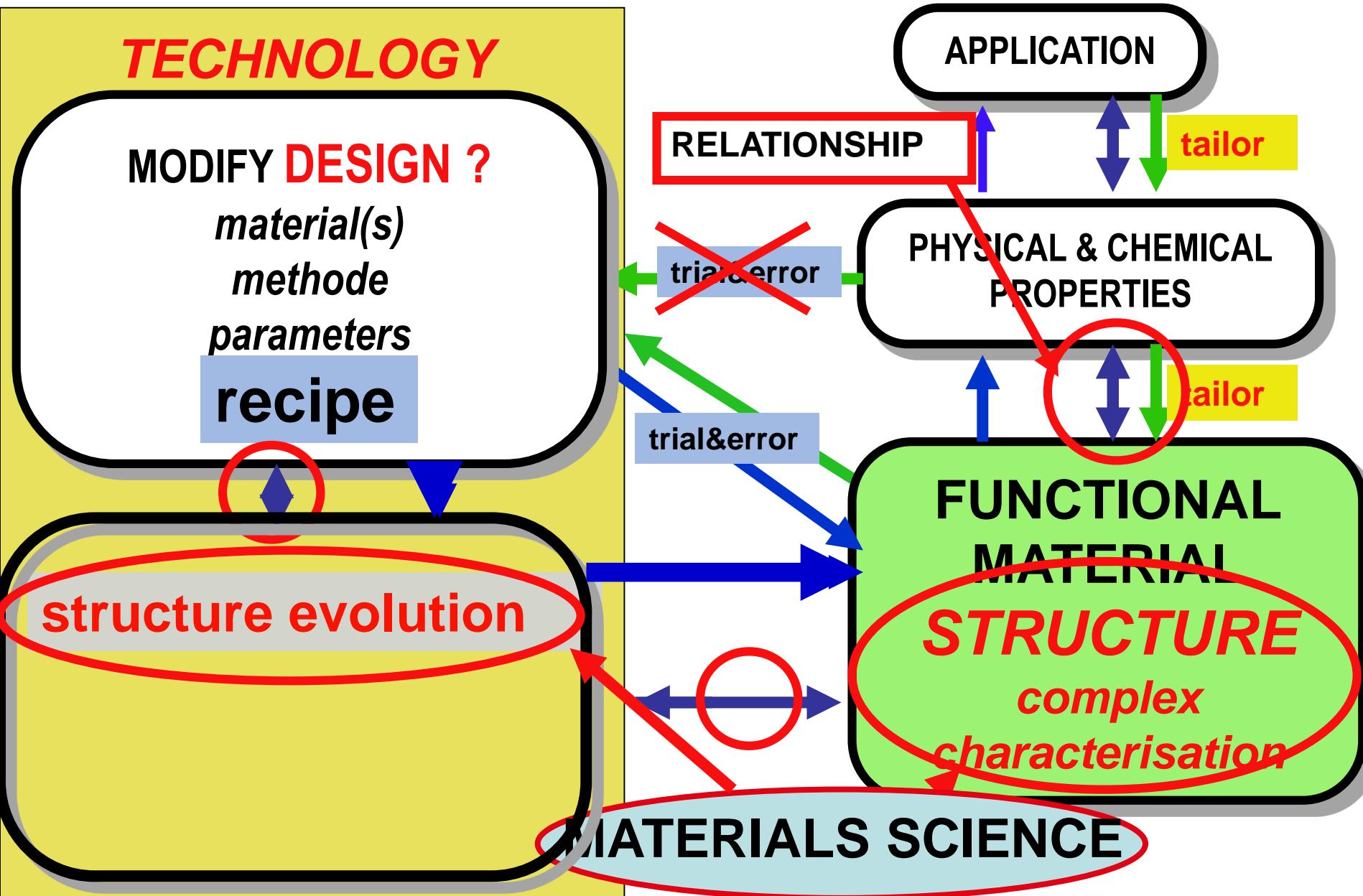
**CONVENTIONAL** way to discover new functional materials  
and improve their quality was the **TRIAL&ERROR**



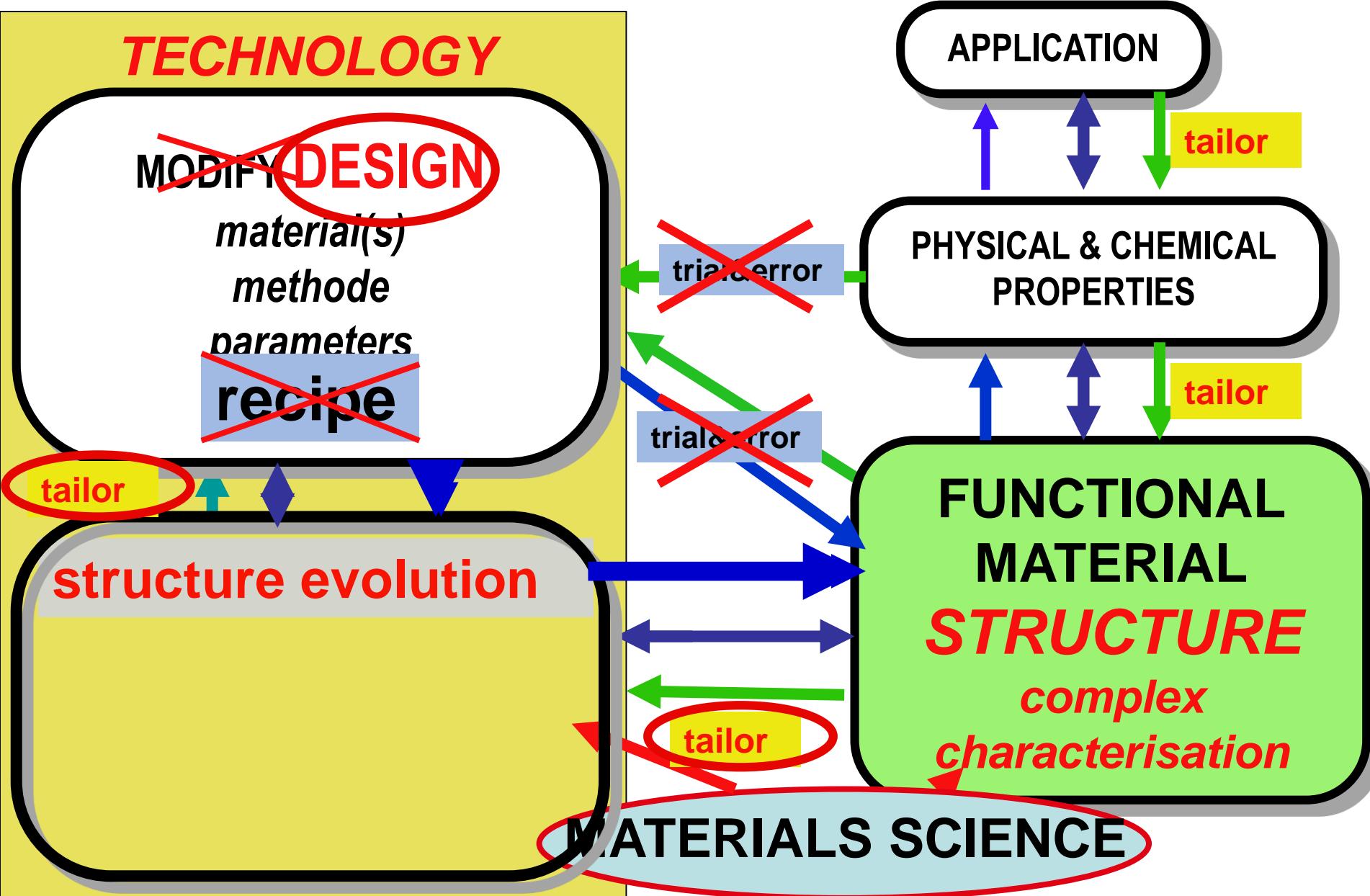
# STRUCTURE CHARACTERISATION made possible to determine the fundamental relationship



# STRUCTURE CHARACTERISATION make possible to determine the fundamental relationship



**MATERIALS SCIENCE** makes possible the **tailoring** of structure and technology to develop and improve advanced functional materials



# **People dealing with functional materials were greatly excited in the middle of 20th century**

- commercialization of materials structure investigation methodes and devices (*X-ray diffraction, electron microscopy.....*) provided the possibility to characterize the materials structure at submicroscopic (nm) level (opening the golden age of materials science)
- **Discovery of single crystal and polycrystalline thin films (from monolayer to  $\mu\text{m}$  thicknesses) constituting of submicroscopic particles provided the possibility to prepare designed sophisticated material structures with new properties by the atom-by-atom deposition**

## **MATERIALS SCIENCE in THIN FILM RESEARCH**

# Preparation of thin films: atom-by-atom deposition in a vacuum system

PRODUCTION  
(source)  
of  
**material(s)** species  
to be deposited



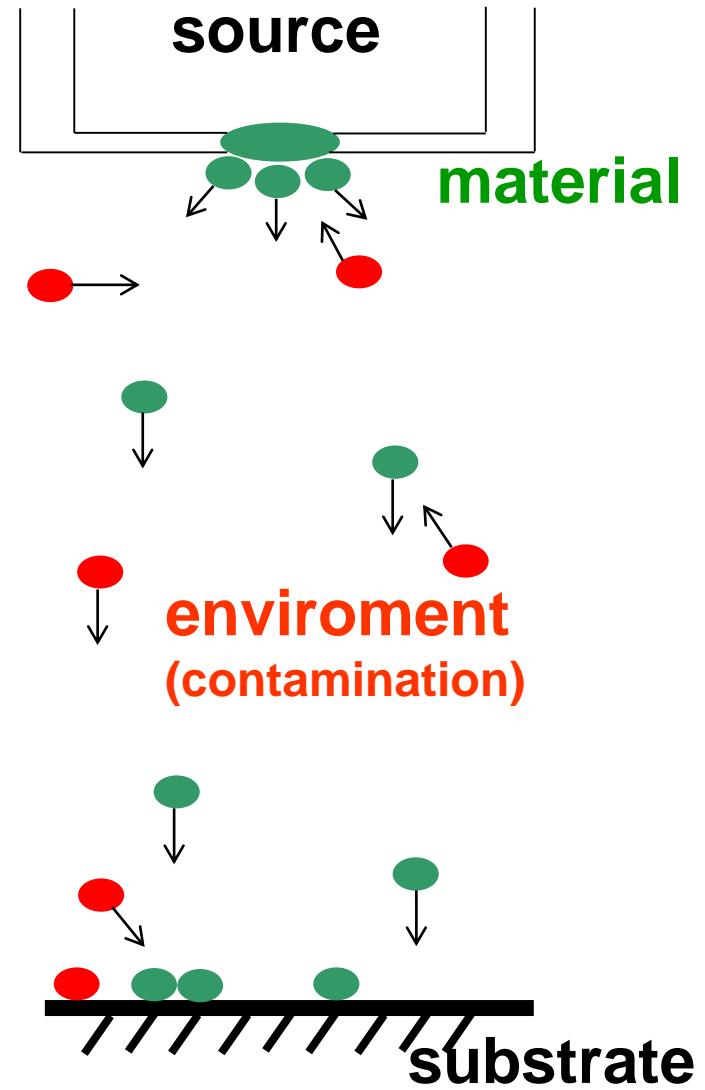
TRANSPORT  
of  
**material** species  
to  
the substrate  
(environment)



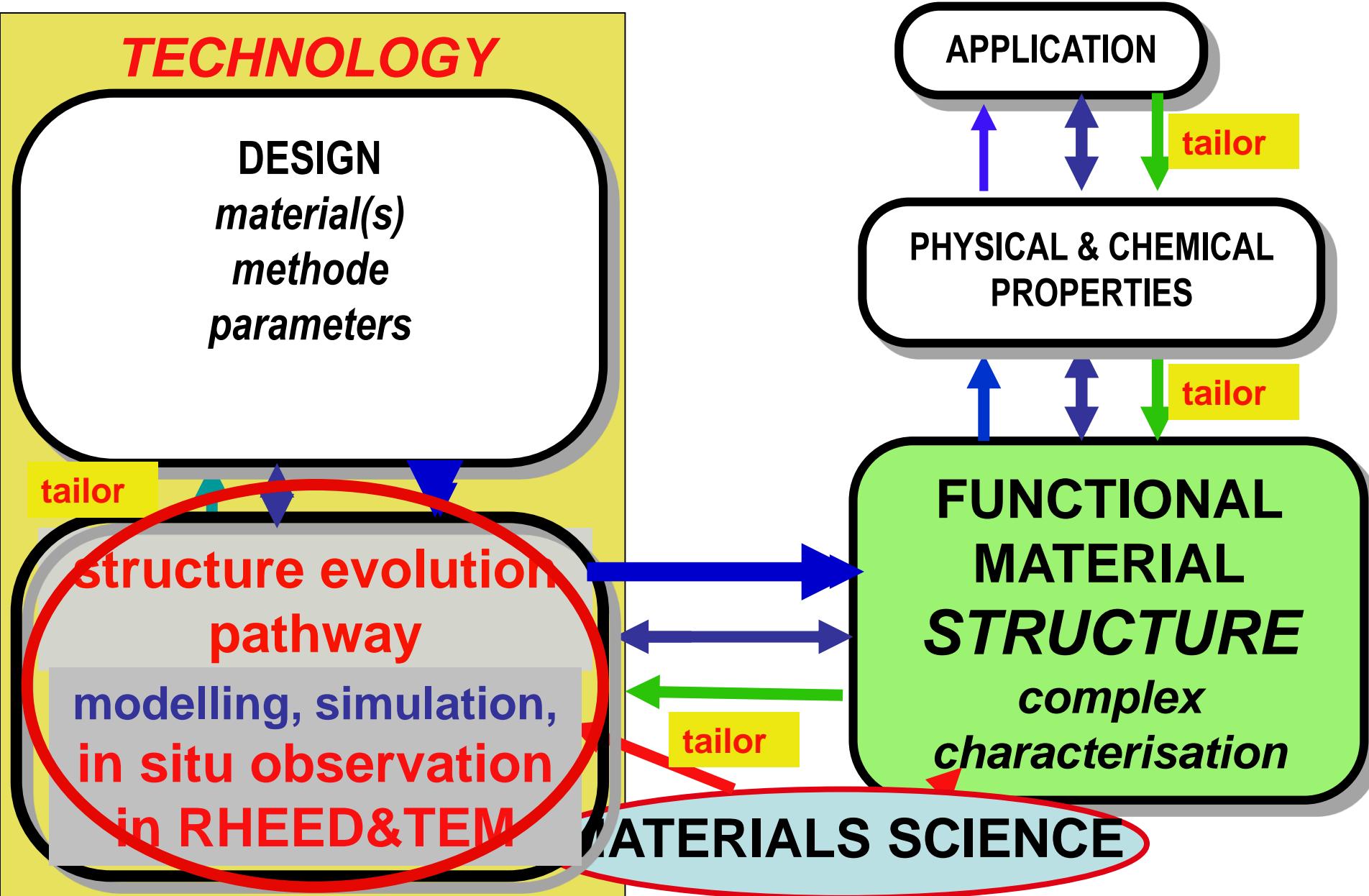
DEPOSITION  
of  
**material-environmental (impurity)** species  
on  
the substrate



EVOLUTION  
of  
the thin film structure



# Vapour deposition of thin films could be realized in electron diffraction units and TEM



## Research teams doing pioneering work to study thin film growth in RHEED and TEM (dates of publication)

T. A. McLauhlan, 1950 (HV - RHEED)

M. Takagi, 1954 (HV - RHEED)

K.J. Hanszen, 1954 (HV -RHEED)

G. A. Bassett, 1958 (HV - TEM)

D. W. Pashley, M.J. Stowell 1964 (HV - TEM)

H. Poppa, 1965 (HV+ **cryo** - TEM)

J. F. Pócza, Á. Barna, P. B. Barna, 1967 (**UHV – TEM + electrical measurements**)

G. Honjo, K. Jagi, 1969 (**UHV - TEM**)

H. Valdre, D.W. Pashley, M.J. Stowell 1970 (**UHV - TEM**)

### Review

Helmut Poppa, *High resolution, high speed ultrahigh vacuum microscopy*, J. Vac. Sci. Technol. A 22 (2004) 1931 - 1947

# OUTLINE

- *initiatives of Prof. Póczta in thin film research (1950/1960)*
- *the UHV in situ TEM experimental system constructed in the Budapest research team*
- *fundamental phenomena and pathway of structure formation of polycrystalline films: case studies of pure In and C doped In thin films*
  - \* *deposition on amorphous substrate: vapour-liquid-solid phase transformation, texture evolution (VIDEO)*
  - \* *fundamental phenomenon of nano-composite structure formation: encapsulation of crystals and repeated nucleation (VIDEO)*
  - epitaxial growth of In, effect of substrate surface contamination, deposition on single crystal MoS<sub>2</sub> substrate (VIDEO)*
- *conclusions*

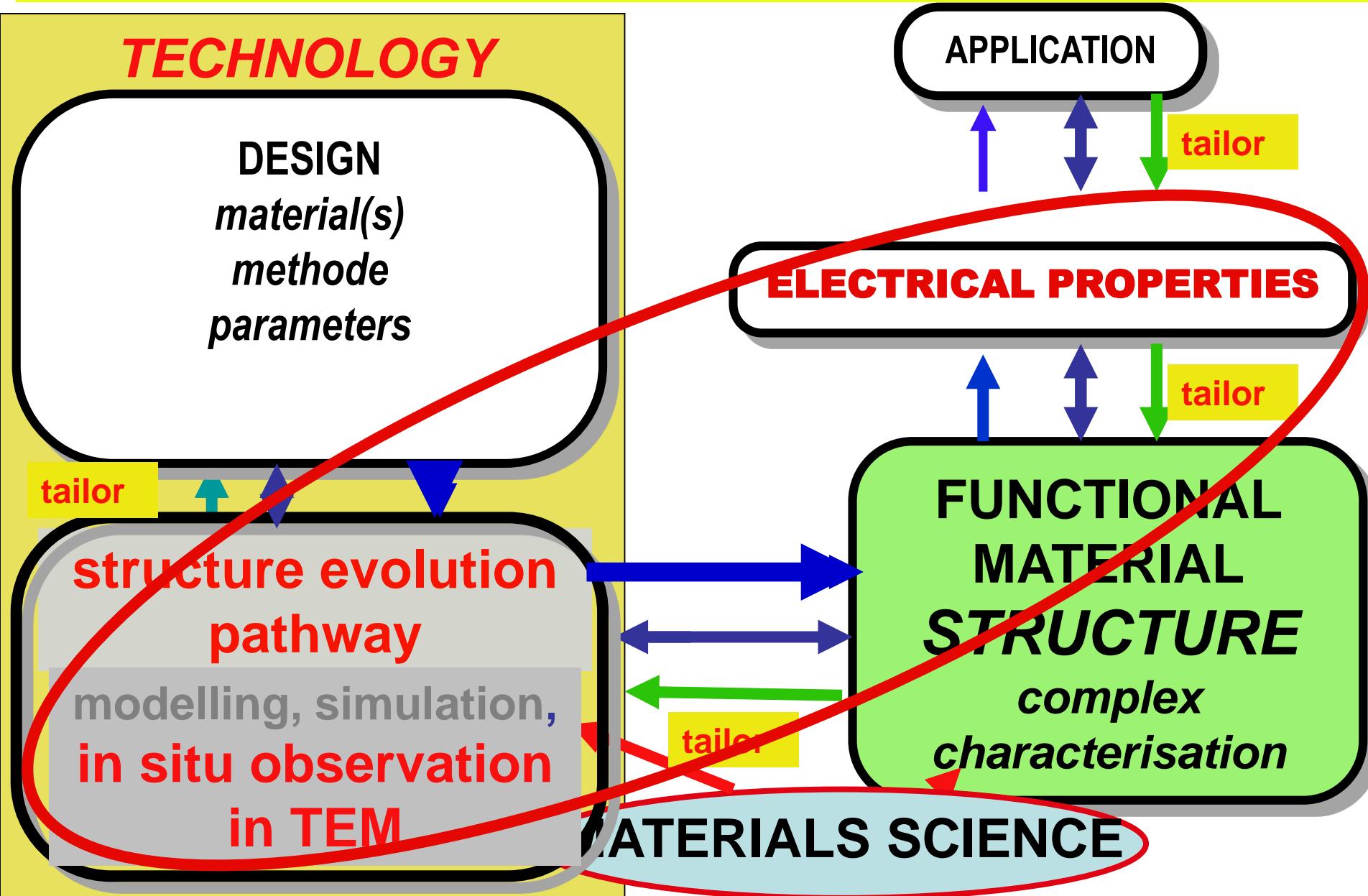
In 1950<sup>th</sup> the RESEARCH PHILOSOPHY of  
**Prof. J.F. Pócza** (1915-1975),  
founder of the Budapest research team was:



**Understanding  
the structure evolution  
and  
the structure - property  
relations**  
are the key issues of  
thin film research and  
technology

# Research phylosophy of Prof. J.F.Pócza

## realize experiments in UHV TEM



# FACILITIES of the In-SITU TEM EXPERIMENTAL SYSTEM developed and constructed in the frame of a PhD work (1963-1978)

Á. Barna: *UHV in situ TEM experimental system for simultaneous investigation of structure evolution and electrical properties of thin films (1982)*

parameters

structure

electrical measurements

during deposition

deposition rate  
**0,05 - 2 nm/s**

substrate temperature  
**-150°C - + 500°C**

residual pressure  
**10<sup>-8</sup>Pa plate, 10<sup>-6</sup> Pa film**  
gas atmosphere < 10<sup>-1</sup> Pa

TEM images  
selected area ED  
low angle TED

resistivity  
(thermo power )(1-3 sec)

during post-deposition treatment

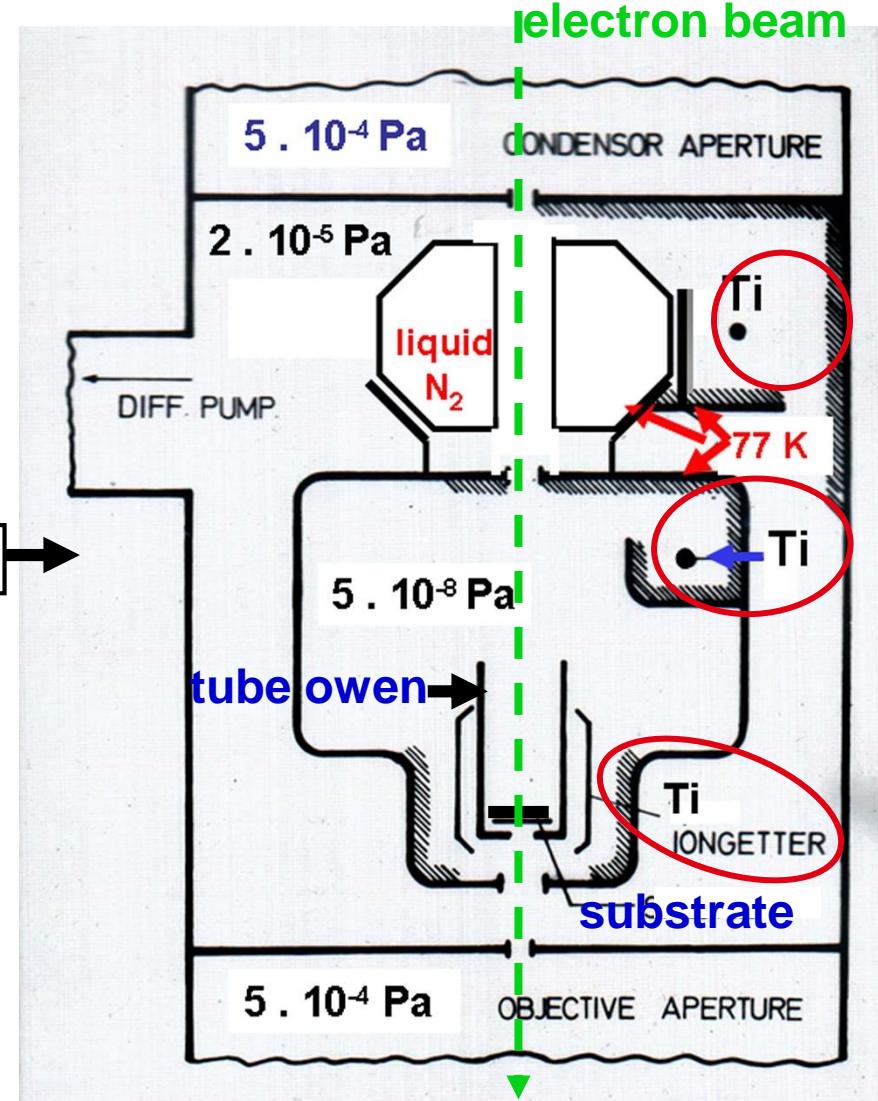
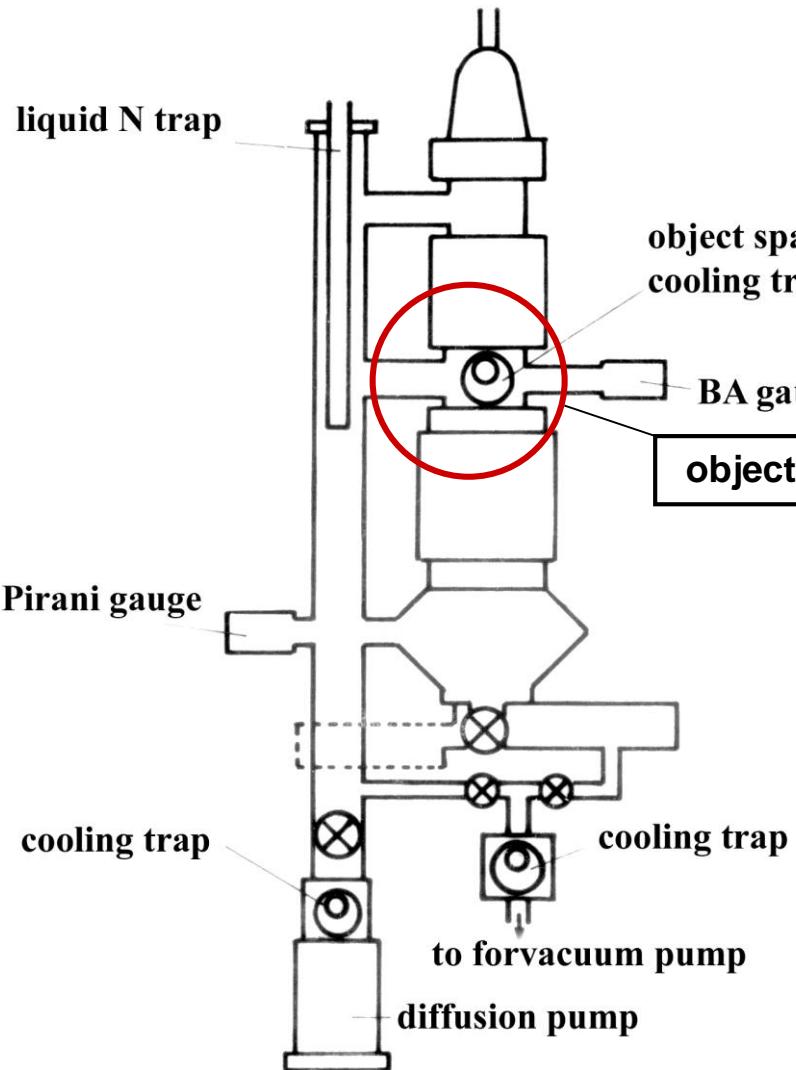
heat treatment  
gas interaction

TEM images  
selected area ED  
low angle TED

resistivity  
thermo power  
Hall voltage  
magneto-resistivity

# The vacuum system of the UHV in situ experimental system

Á.Barna, P.B.Barna, J.F.Pócza: Vacuum, 17, (1967) 219-221



Vacuum system of JEM 6A TEM

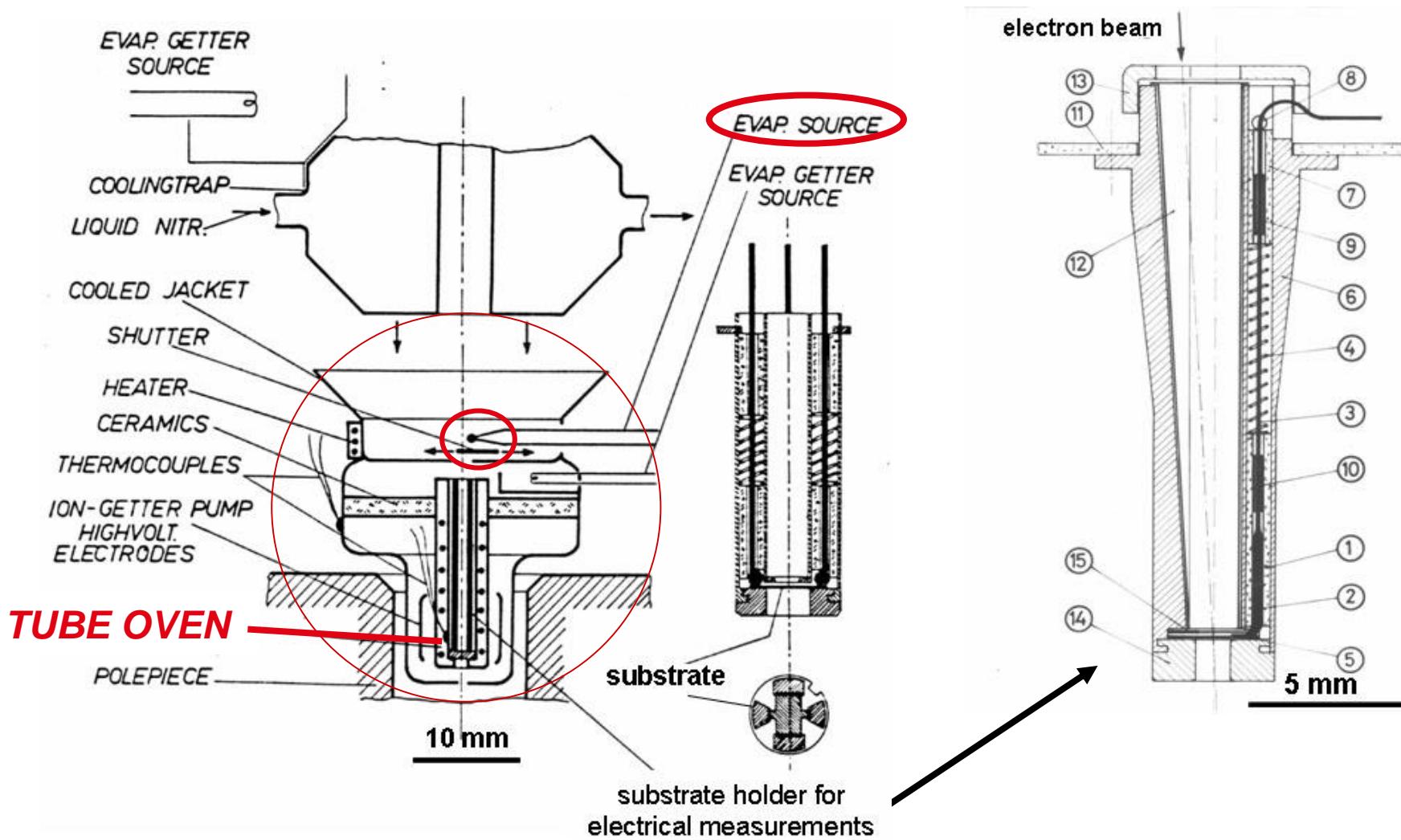
Vacuum system of the in situ experiments

# Scheme of the UHV in-situ experimental system dedicated to electrical measurements

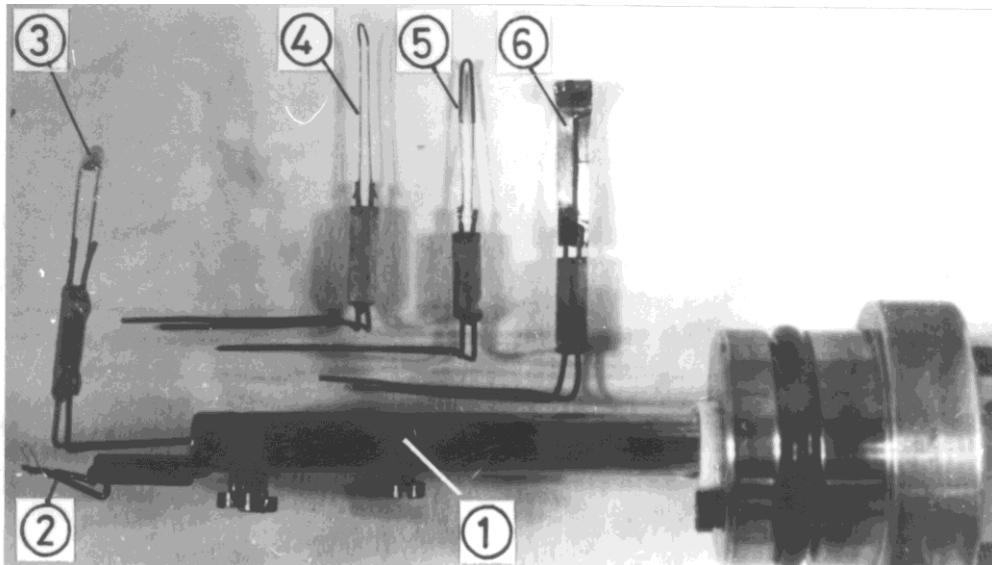
Á.Barna, P.B.Barna, J.F.Pócza: Vacuum, 17, (1967) 219-221

Á. Barna, P.B. Barna, J.F. Pócza: Septième Congr. Int. Micr. Électronique, Grenoble, (1970) pp. 445-446.

Á. Barna, P.B. Barna, G. Stark, P. Thomas, L. Tóth: Proc. 7th Int.Vac.Congr. Vienna, 1977. Vol. II. p. 1635

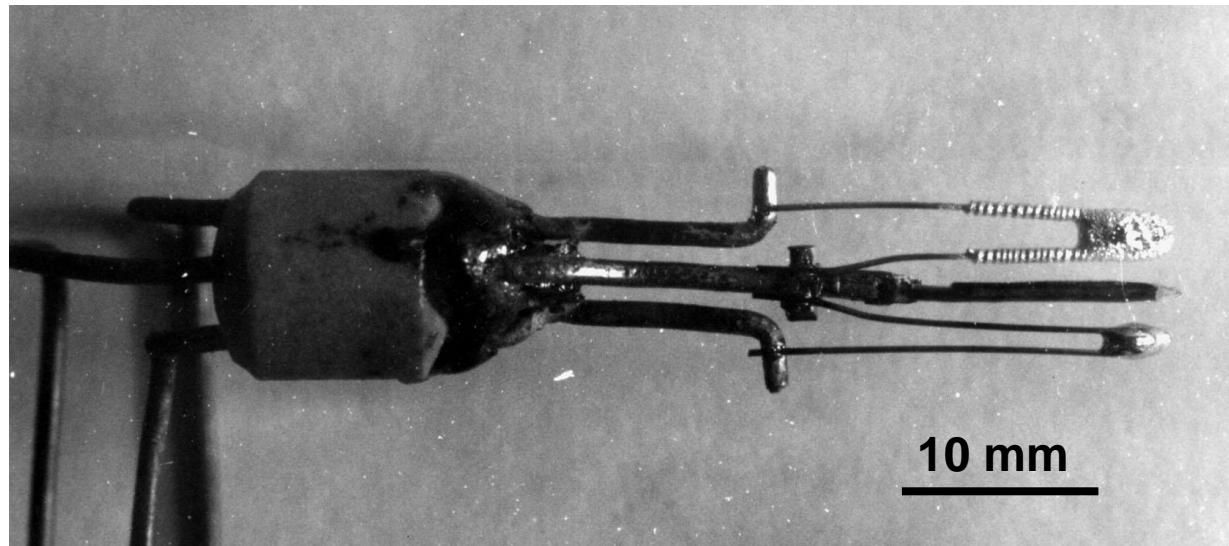


# The evaporation sources for various materials

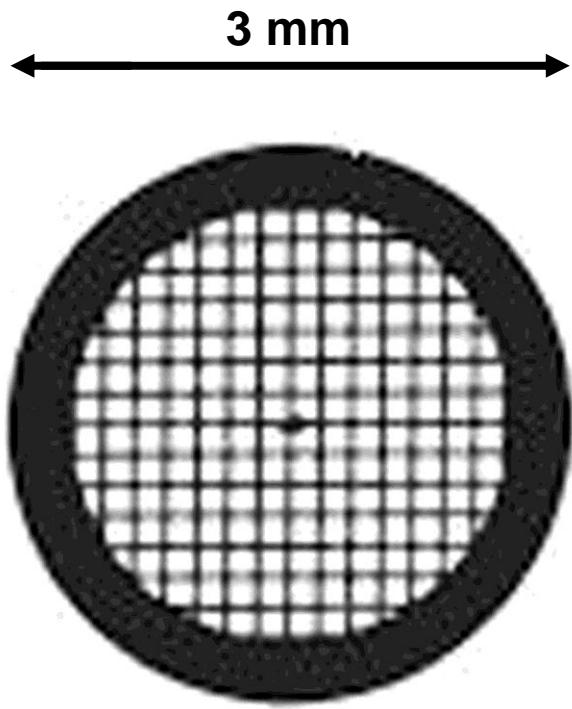


- 1 source holder
- 2 optical pyrometer
- 3 Al
- 4 Au
- 5 Ge
- 6 miniature crucible for Sn, Bi

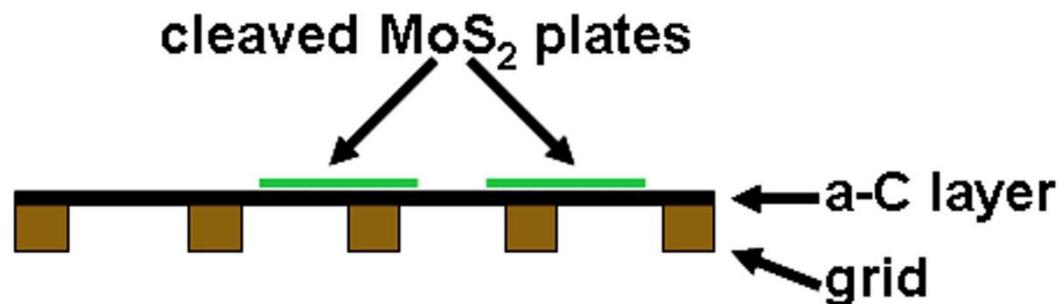
source for sequential deposition of Al and Au



# a-C or SiO<sub>2</sub> layer substrates were prepared on TEM microgrids



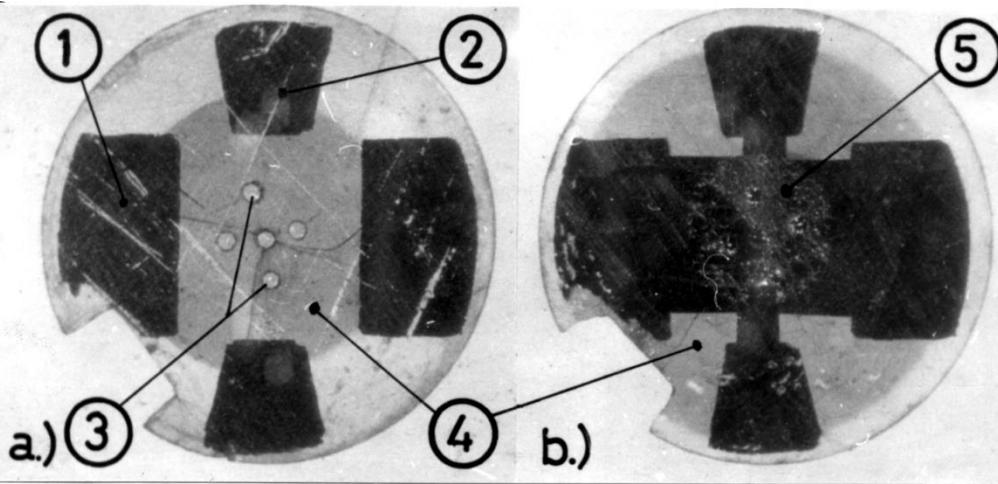
Substrate for polycrystalline film growth and texture evolution on amorphous substrates



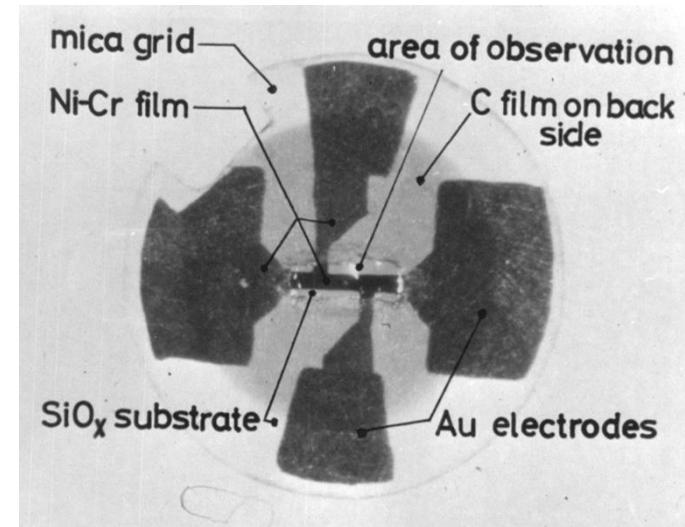
The metall microgrid

Substrate for epitaxial growth experiments

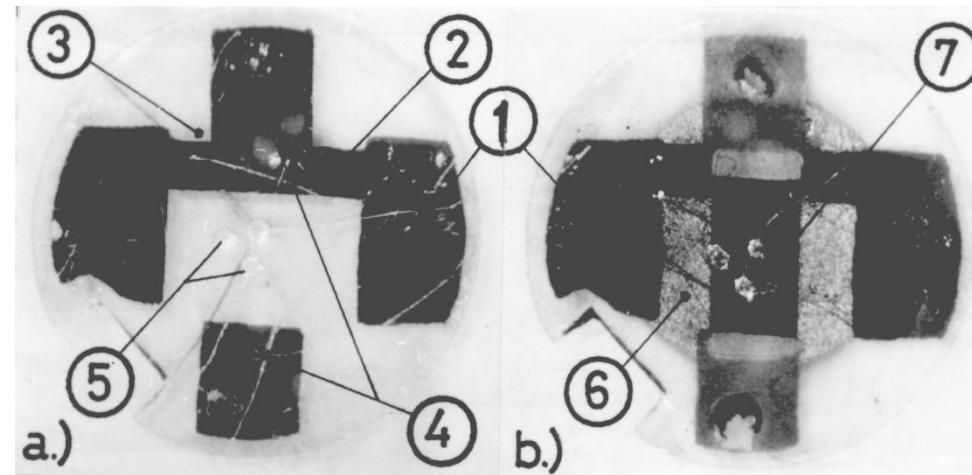
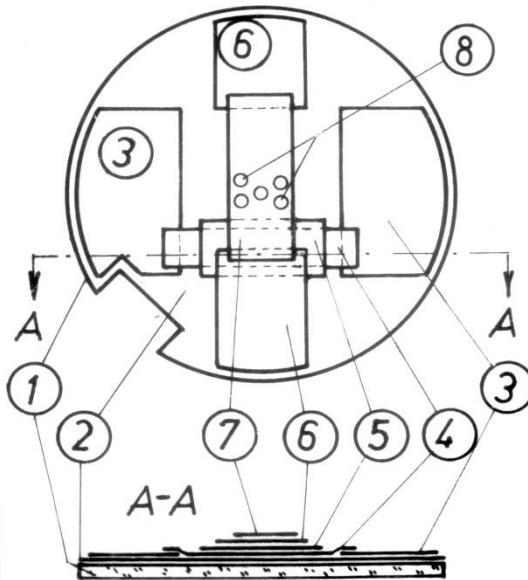
# SUBSTRATES DEDICATED to ELECTRICAL MEASUREMENTS on mica microgrids



Hall voltage

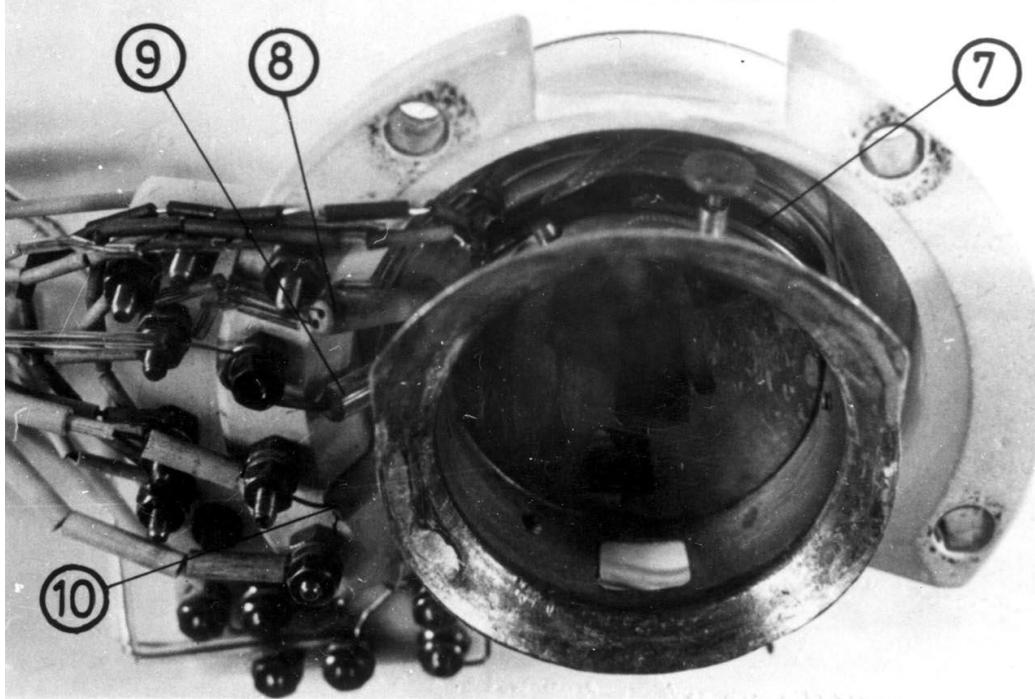


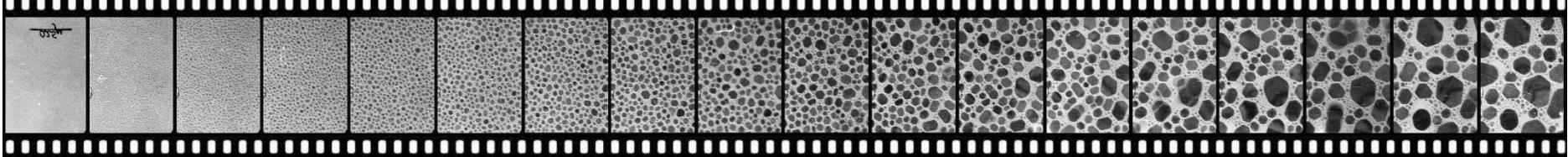
Resistivity



Thermo power

# The cartridge of the experimental system





## ***Members of the research team realizing the *in situ* TEM experiments in 1963 – 1984***

**J.F. Pócza (leader - 1975)**

**Á. Barna, P. B. Barna (leader 1975-1984), Z. Bodó, G. Sáfrán,  
I. Pozsgai, G. Radnóczki, L. Tóth,**

**Guest researchers:**

**Á. Csanády (Hungalú, Aluterv-FKI, Budapest )**

**L. Lomniczy (Res, Inst. Development of Sci. Instr. Budapest)**

**A. Dévényi (Institute of Physics, Bucharest)**

**I. Rechenberg (Humboldt Universität, Berlin),**

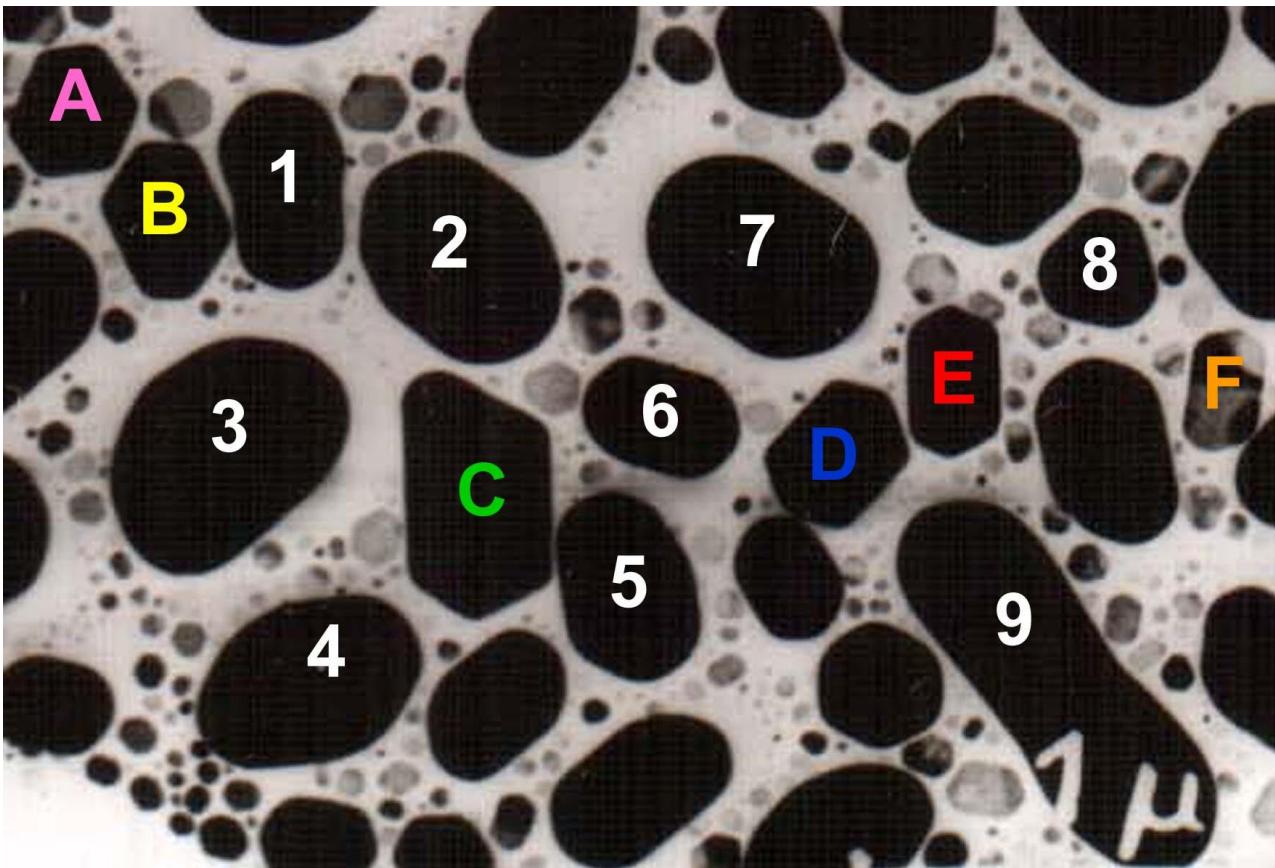
**H. Sugawara (Tokyo University),**

**P. Thomas (Phillips Universität, Marburg)**

**Assistants**

**K. Raffay, É. Hajmássy, L. Puskás, G. Barcza, Gy. Glázer**

# Dumfounding structures shown up in earlyTEM studies



30 nm thick In film  
deposited on a-C  
layer substrate at  
 $60^{\circ}\text{C}$  ( $T_s = 0.77 T_m$ )

## \* COEXIST

- large and very small grains
- well faceted crystals of various sizes **A, B, C, D, E, F**, and more rounded ones (marked with numbers)

\* ROUNDED CRYSTALS are situated in bare substrate surface domains 2, 3, 7

**Stimulating question: How this unusual structure can develop?**

# Topics investigated by in situ UHV TEM 1963 - 1984

## Indium : fundamental phenomena of structure formation

- amorphous-single crystal substrates: vapour-liquid-solid phase transformation, melting point-size dependence
- nucleation, coalescence, crystal growth, development of texture
- effect of inhibitor additive, fundamental process of the evolution of nanocomposite structure
- epitaxial growth on MoS<sub>2</sub>: effect of substrate contamination

## -Ge, Sb films

- evolution and restructuring of amorphous structure during heat treatment, dependence of the conduction mechanism on structure
- crystallisation of amorphous thin films during heat treatment, effect of contamination: nucleation, crystal growth, activation energy
- conduction mechanism of crystallized films, dependence of grain boundary barrier on level of contamination

## NiCr resistor films

- restructuring during heat treatment: chemical reactions, formation-segregation of phases, their effects on the electrical conduction mechanisms

## Oxidation of Al films

## Formation of phases at sequential/multilayer deposition

- nucleation and growth of intermetallic phases at solid surface - vapour phase reaction, effect of surface contamination (sequential deposition of Al and Au)

# **EXPERIMENTS**

## **Growth of In films on a-Carbon substrate**

**\* effect of substrate temperature**

**dependence of melting temperature on crystal size**

**vapour-liquid-solid phase transition**

**coalescence of liquid droplets and crystals, texture evolution  
growth of crystals**

**\* co-deposition of carbon: encapsulation of In crystals by a-C layer**

- Á.Barna, P.B.Barna, J.F.Pócza: Proc.Czechoslovak Summer School on Thin Films, Ledec, 1967, 71-126
- Á.Barna, P.B.Barna, J.F.Pócza: Vacuum, 17, (1967) 219-221
- J.F.Pócza: Proc. II. Coll. on Thin Films, (ED. E.Hahn, Akadémiai Kiadó, Budapest) (1967) pp.93-108
- Á. Barna, P.B. Barna, J.F. Pócza: J.Vac.Sci.Techn. 6(1969)472-474
- J.F.Pócza: Proc. Int.Conf. on Phys. and Chem. of Semiconductor Heterojunctions and Layer Structures (Akadémiai Kiadó, Budapest) (1971)Vol. III, pp.61-82
- J.F.Pócza, Á.Barna, P.B.Barna, I.Pozsgai, G.Radnóczki, Japan JAP, Suppl. 2. Part 1, (1974) 525
- P.B. Barna:Diagnostics and Application of thin films (Ed. L.Eckertova, I.Ruzicka) Inst. of Physics Publishing, Bristol, (1992) pp. 295-309.
- P.B. Barna, M.Adamik: Science and Technology of Thin Films, eds.: F.C.Matacotta and G.Ottaviani, World Scientific Publishing Co., (1995) p. 1-28.
- P.B.Barna, M.Adamik: Protective Coatings and Thin Films: Synthesis, Characterisation and Applications, NATO ASI Series, 3. High Technology, Vol.21, (1997) (Eds.: Y.Pauleau and P.B.Barna, Kluwer Academic Publishers, Netherlands) pp.279-297.(Proc. NATO HTECH.ARW 950730, 1996, Portimao, Algarve, Portugal)
- P.B.Barna, M.Adamik Thin Solid Films 317 (1-2) (1998) pp. 27-33.
- I.Petrov, P.B.Barna, L.Hultman, J.E.Greene: J.Vac.Sci.Technol. A 21(5) (2003) S117-S128
- P.B. Barna, G. Radnóczki, Structure formation during deposition of polycrystalline metallic films, in K. Barmak&K.Coffey (Ed), Metallic films for electronic, optical and magnetic applications, Woodhead Publishing Series in Electronic and optical Materials 40(2014)67-120

# Nucleation, growth and coalescence of liquid In droplets

$T_s = +90^\circ\text{C}$ , 0,85  $T_m$

$5 \cdot 10^{-5} \text{ Pa}$



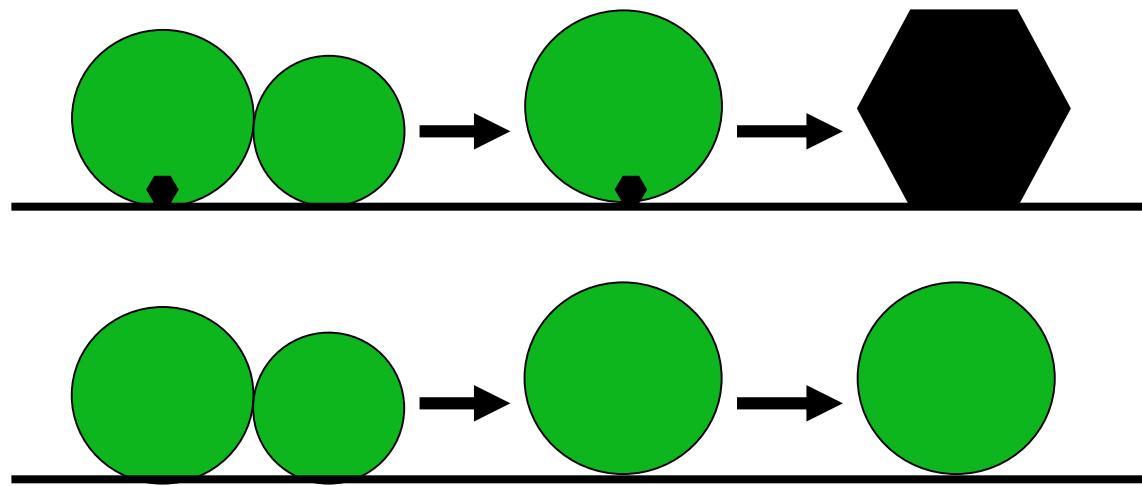
0,5  $\mu\text{m}$



$$T_S = +80^\circ\text{C}, \ 0,82 T_m$$

$$P = 4 \cdot 10^{-5} \text{ Pa}$$

- Nucleation in liquide phase
- Growing or coalescing liquid droplets containing „active nuclei” crystallize beyond a critical size

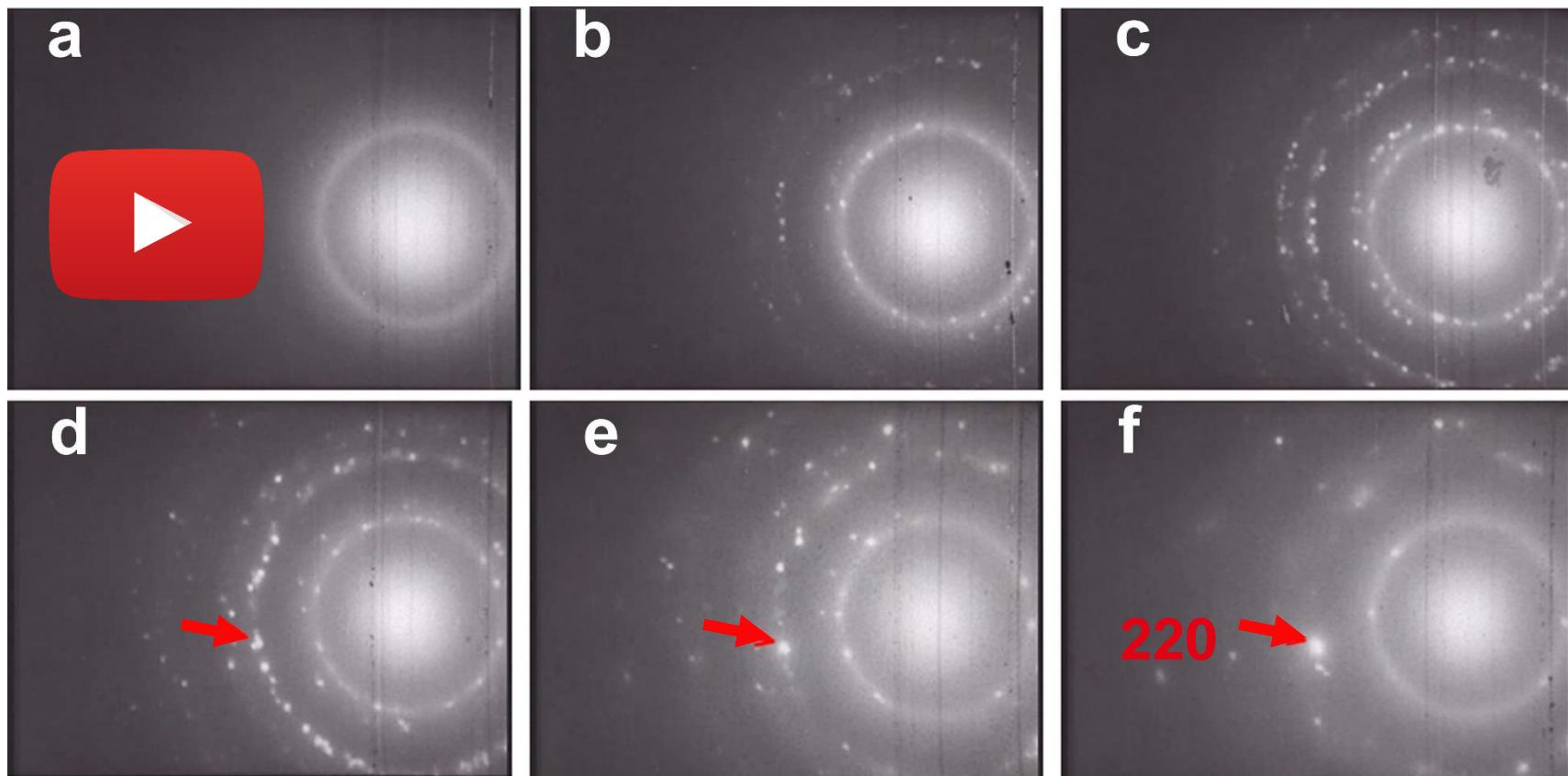


THE FIRST CRYSTAL WILL SHOW UP



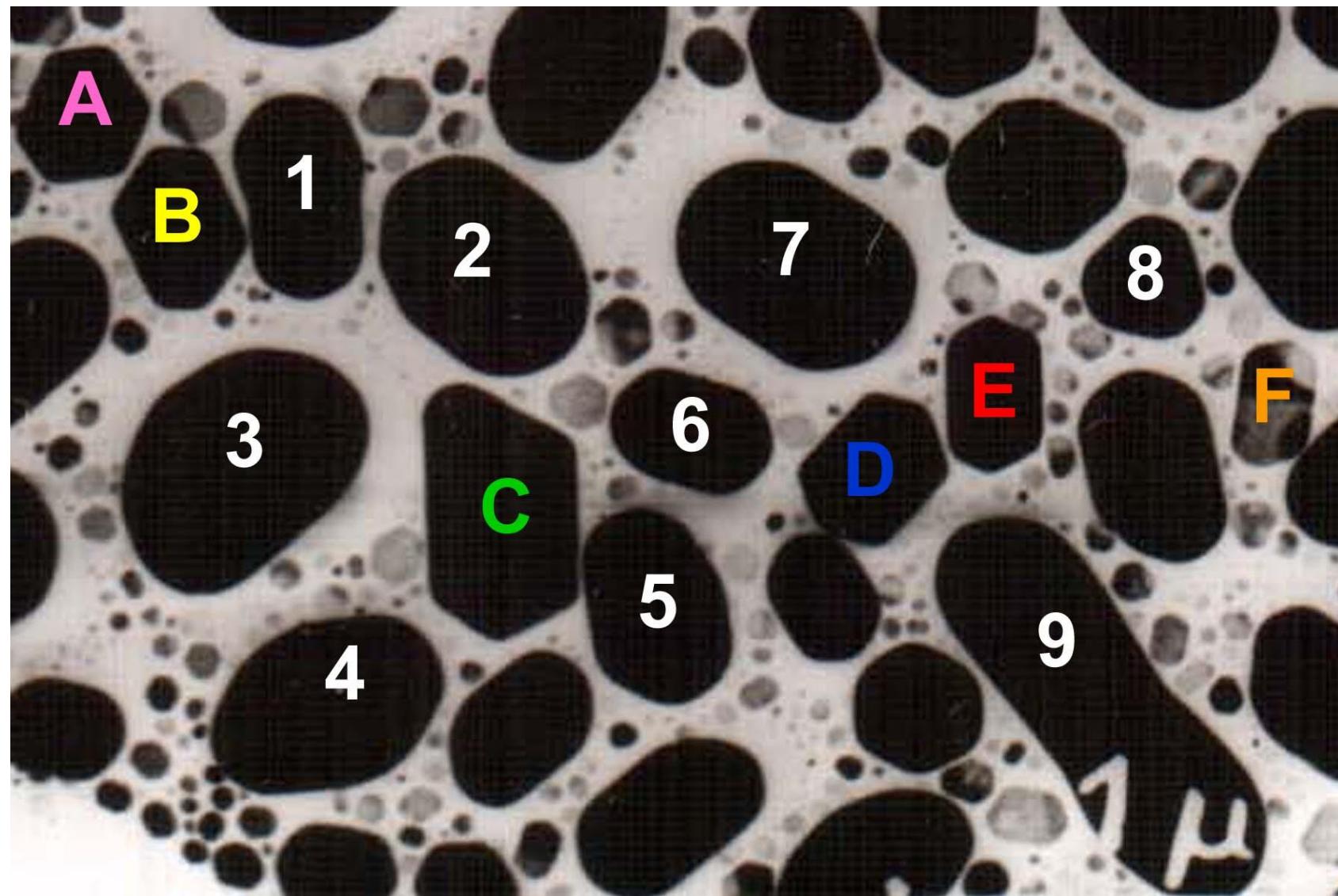
The same process is followed by selected area electron diffraction: pathway of structure evolution *development of texture by coalescence*

- nucleation of liquid droplets
- **crystallization** of liquid droplets: the number of randomly oriented crystals increases,
- **coalescence** of liquid droplets/crystals: the material is accumulated stepwise into the crystals with the lowest interface energy and the [111] **texture develops**



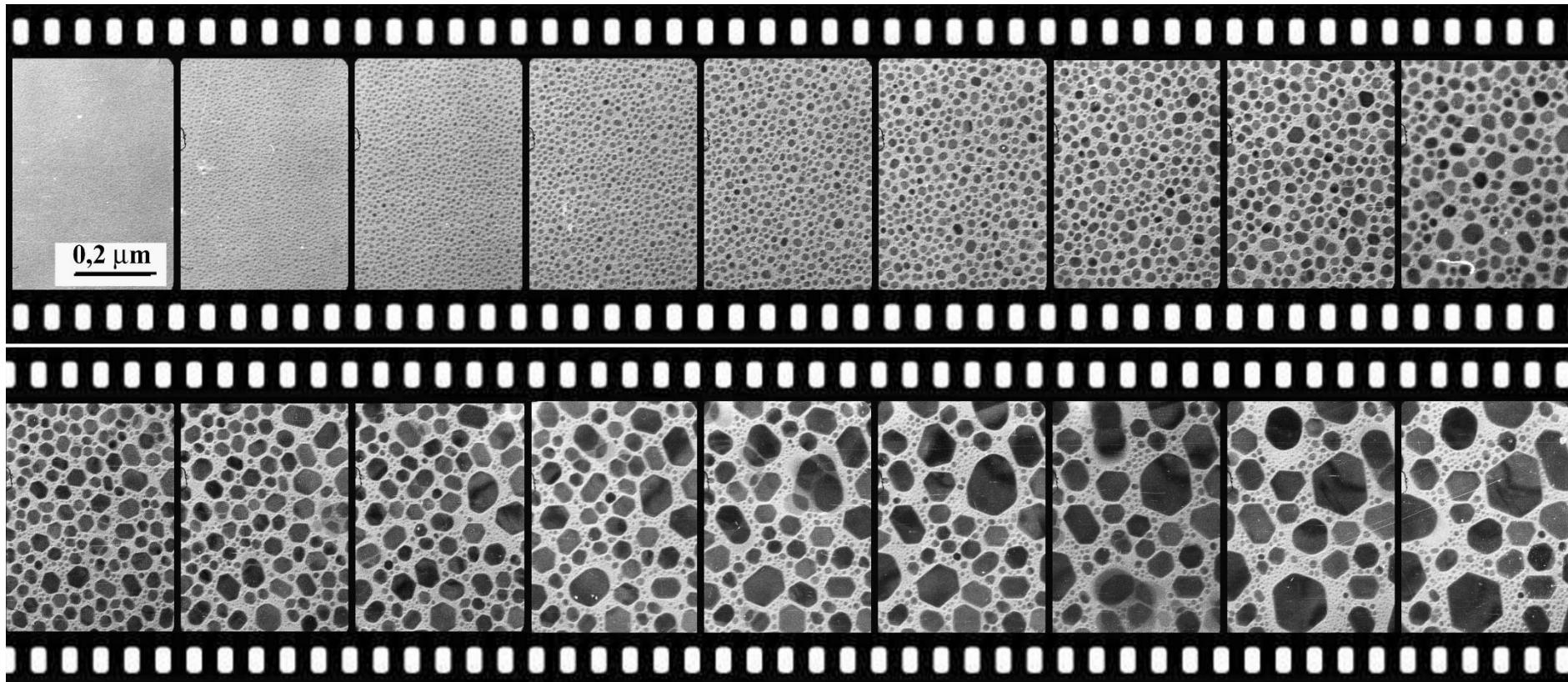
# Development of the unusual structure

In deposition at  $60^{\circ}\text{C}$  ( $0,77 T_m$ ) and  $10^{-7}\text{Pa}$ , depositon rate 2 nm/s,

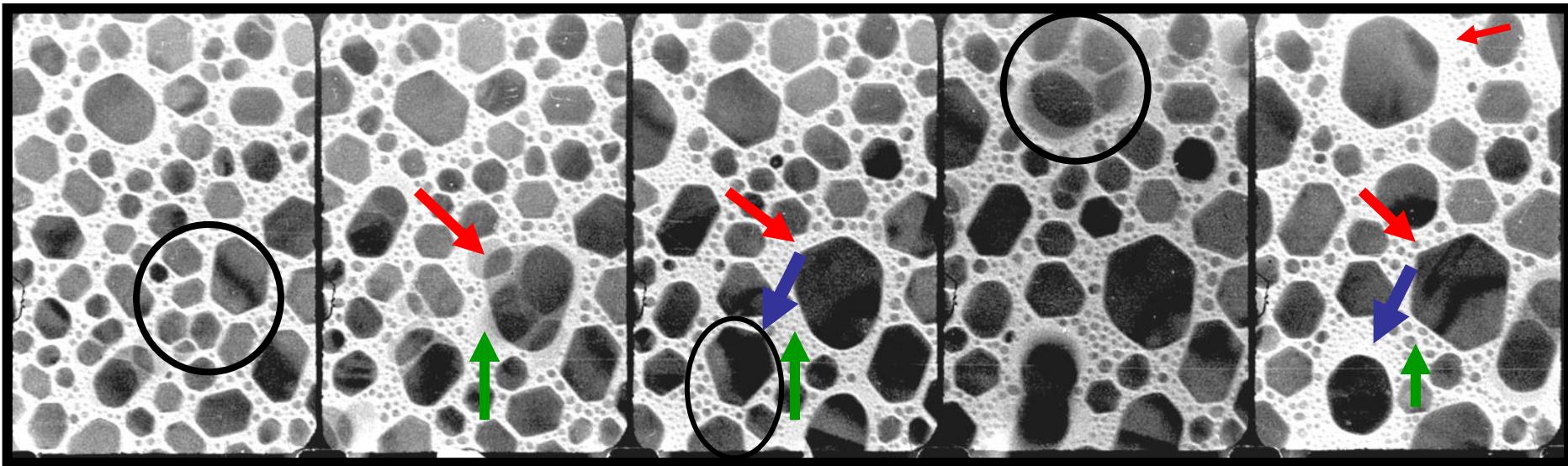


# ***The fundamental phenomena of structure evolution:***

In deposition at  $60^{\circ}\text{C}$  ( $0,77 T_m$ ) and  $10^{-7}\text{Pa}$ , depositon rate 2 nm/s,



- nucleation: primary and secondary on the substrate
- crystal growth
- grain growth by liquid-like coalescence



- **Grain growth by liquide-like coalescence:**
  - \* rounded crystals develop
  - \* bare substrate surface area
  - \* secondary nucleation

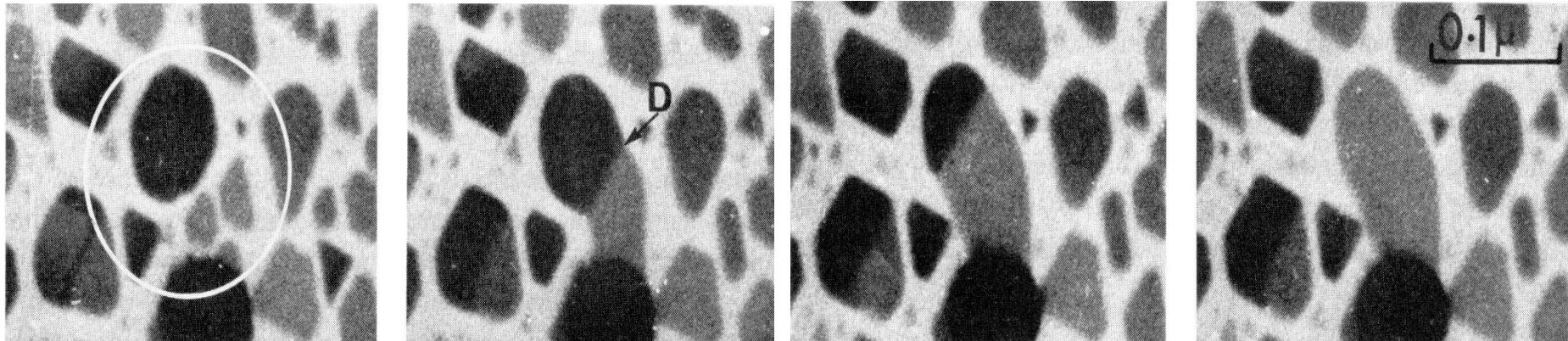
- **Crystal growth develops faceted crystals !!!**

# Solid phase coalescence

Au deposition on cleaved 0002 MoS<sub>2</sub> surface at 670 K ( $T_s/T_m = 0.5$ )

(Stowell, M.J., in Dauglis E, Gretz R.D., Jaffee R.J. Molecular Processes on Solid Surfaces, McGraw –Hill, 1969, pp.461-477)

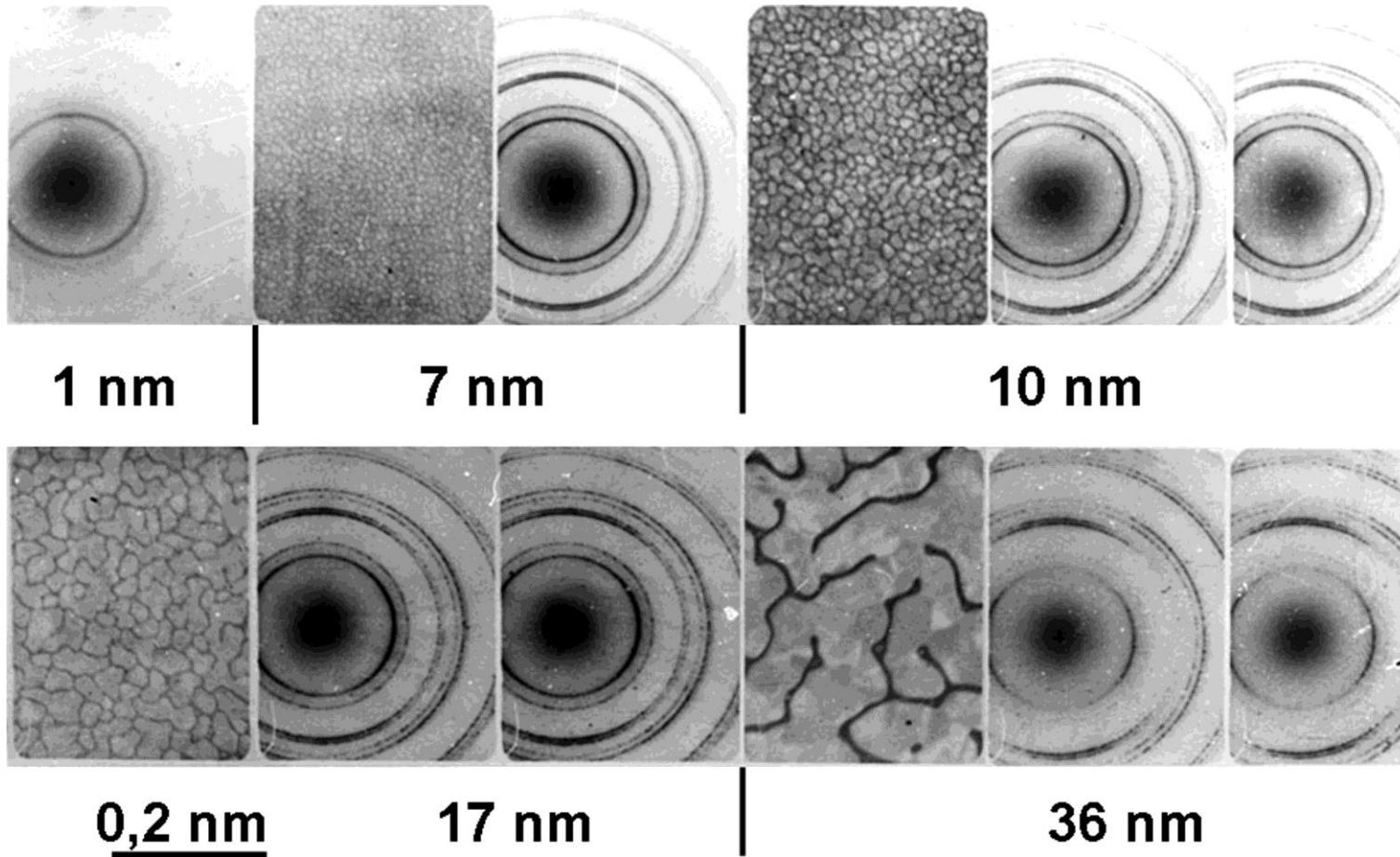
- grain boundary migration (slow)
- reorientation
- no secondary nucleation



# Development of the [111] texture in In film during growth

$T_s = -70^\circ\text{C}$ ,  $0,47 T_m$ ,  $10^{-5}\text{Pa}$ ,  $0,2 \text{ nm/s}$

In situ experiment on tilted substrate, alternately taken images and SAED patterns

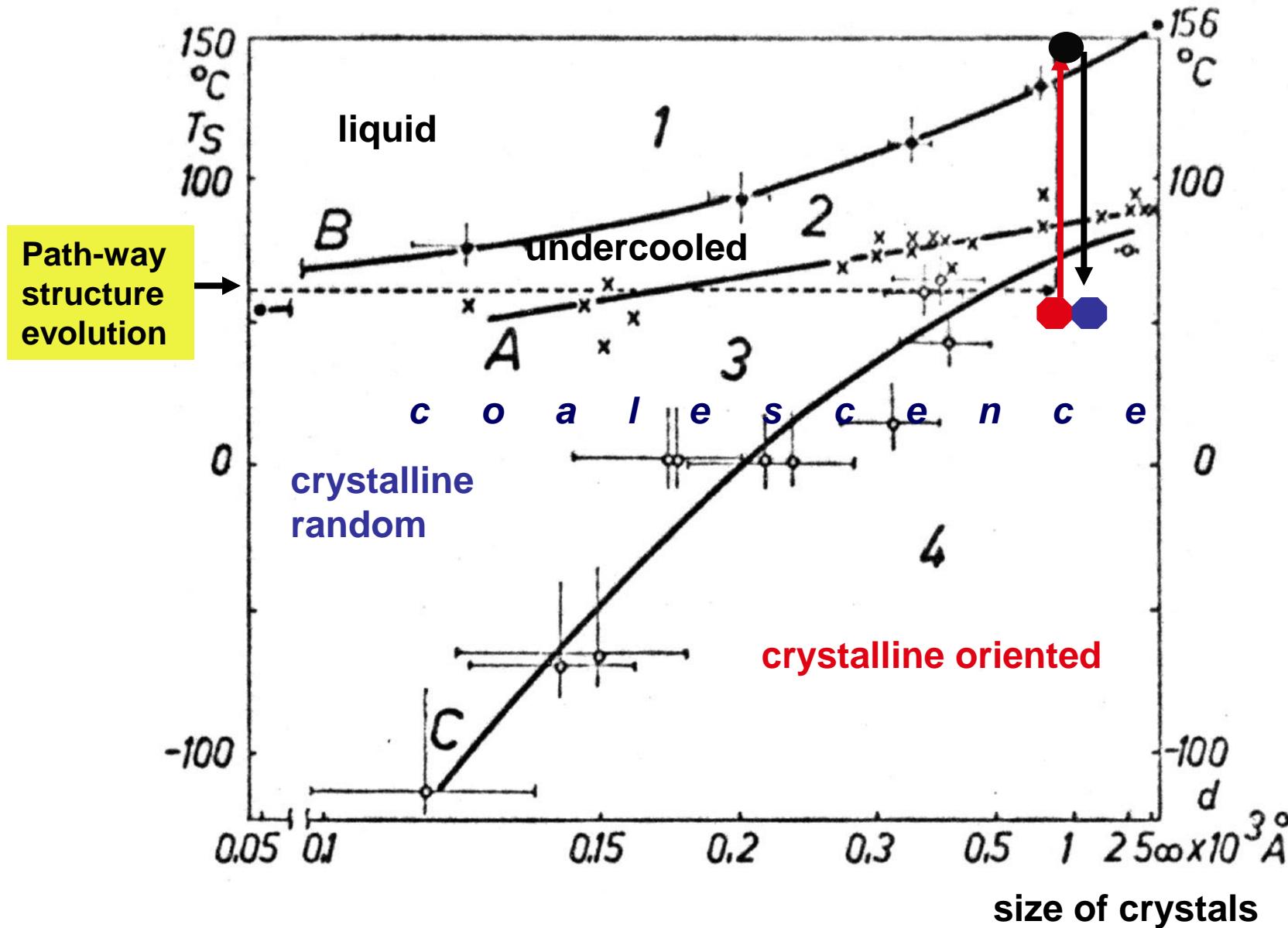


**Video:**  $T_s = -150^\circ\text{C}$ ,  $0,29 T_m$



# Results made possible to develop the phase diagram of In crystals and the path-way of structure evolution

Á. Barna, P.B. Barna, J.F. Pócza: J.Vac.Sci.Technol. 6(1969)472-474





## CO-DEPOSITION of indium & carbon

$T_S = +75 \text{ } ^\circ\text{C}$

$P_{\text{total}} = 5 \times 10^{-6} \text{ Torr}$  without COOLING TRAP

$E = 5 \text{ \AA/s}$



$N = 14 \text{ 000 x}$

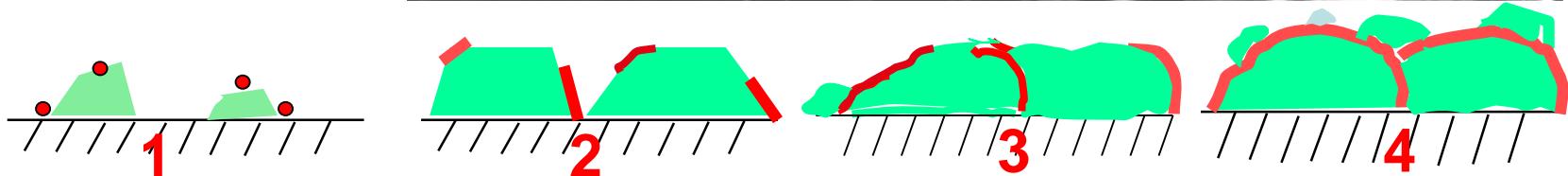
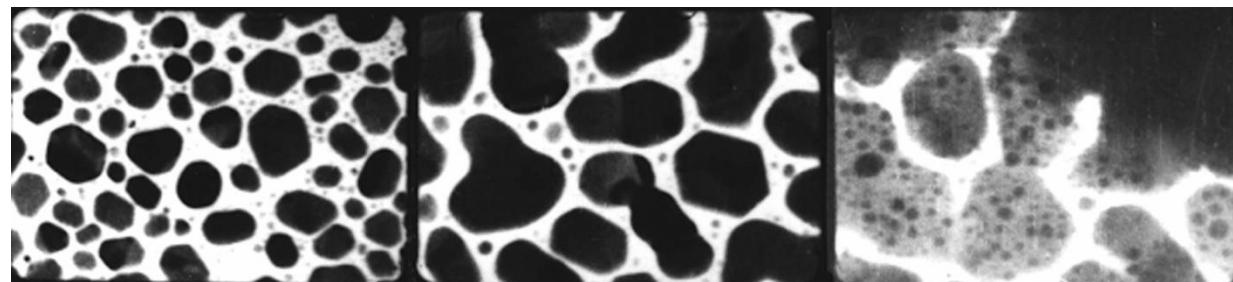
$0,5 \text{ } \mu\text{m}$



—

Fundamental mechanism of the nanocomposite structure evolution:  
encapsulation of the In crystals by C layer developed by segregation

## Mechanism of the encapsulation of In crystals by a-C layer



### 1 In crystals nucleate at first and grow on the substrate

-the condensing **C** species are segregated by the crystal growth processes to the surface of the In crystals

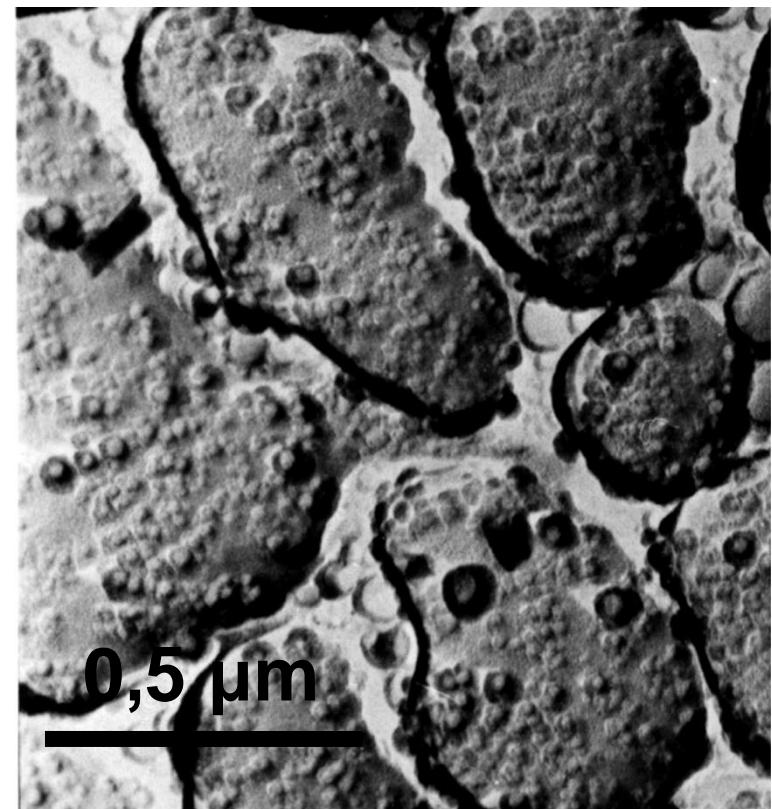
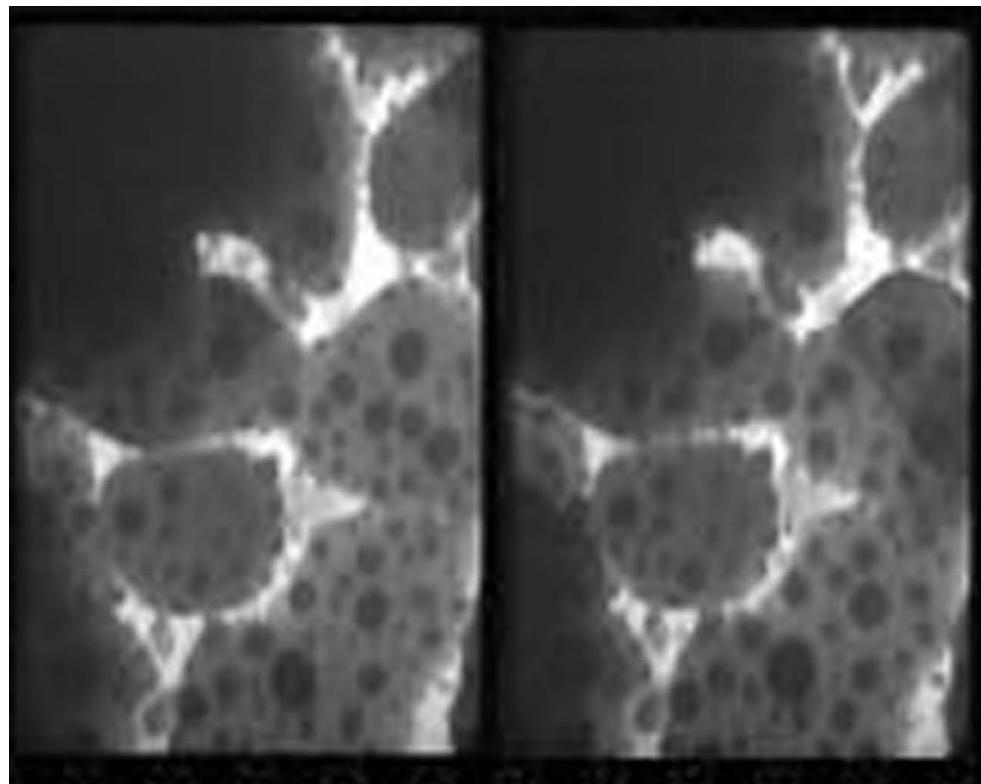
### 2 segregated C species nucleate an **a-C phase on the In crystal's surface**

-the **C phase is growing in a 2D layer (tissue phase)** along the surface of In crystals blocking the crystal growth locally (rounding the crystal shape), **encapsulation starts**

### 3 the **C phase incorporates into the grain boundaries** at impinging of crystals and limit the grain growth, **texture evolution is limited**

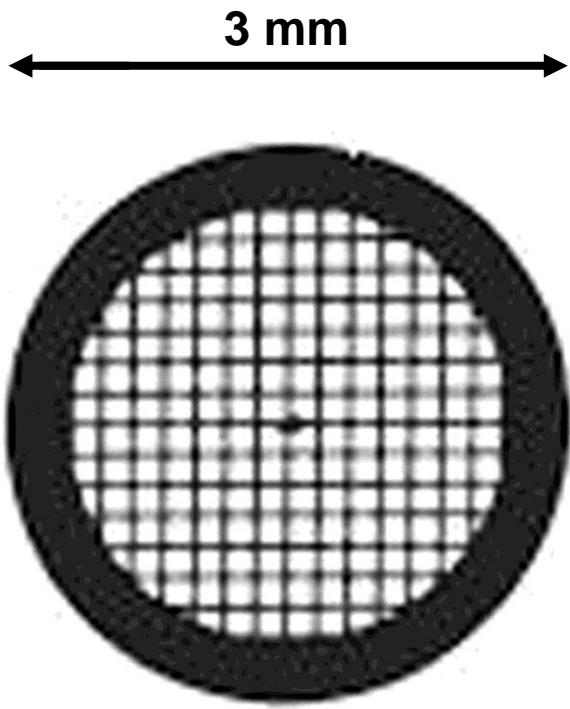
### 4 when the **encapsulation** of In crystals by the C layer is **completed**, the condensation of In results in **repeated nucleation** - The whole growth process is continued

# **Crystals developed by repeated nucleation on the surface of In crystals encapsulated by a-C layer**



# **Deposition of In on air cleaved {0001} surface of MoS<sub>2</sub> crystals**

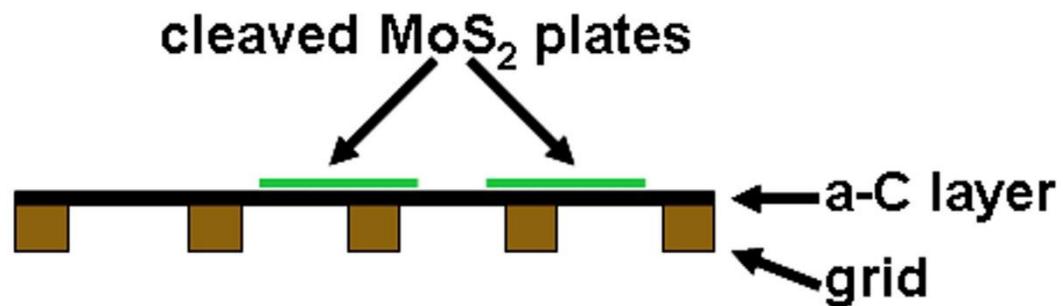
# a-C or SiO<sub>2</sub> layer substrates were prepared on TEM microgrids



3 mm



Substrate for polycrystalline film growth and texture evolution on amorphous substrates



The metall microgrid

Substrate for epitaxial growth experiments

# **Epitaxial growth of In film on air cleaved 0001 MoS<sub>2</sub> surface effect of substrate surface contamination**

**T<sub>S</sub> = 100°C, 0,86T<sub>m</sub>**

**2 . 10<sup>-6</sup>Pa**

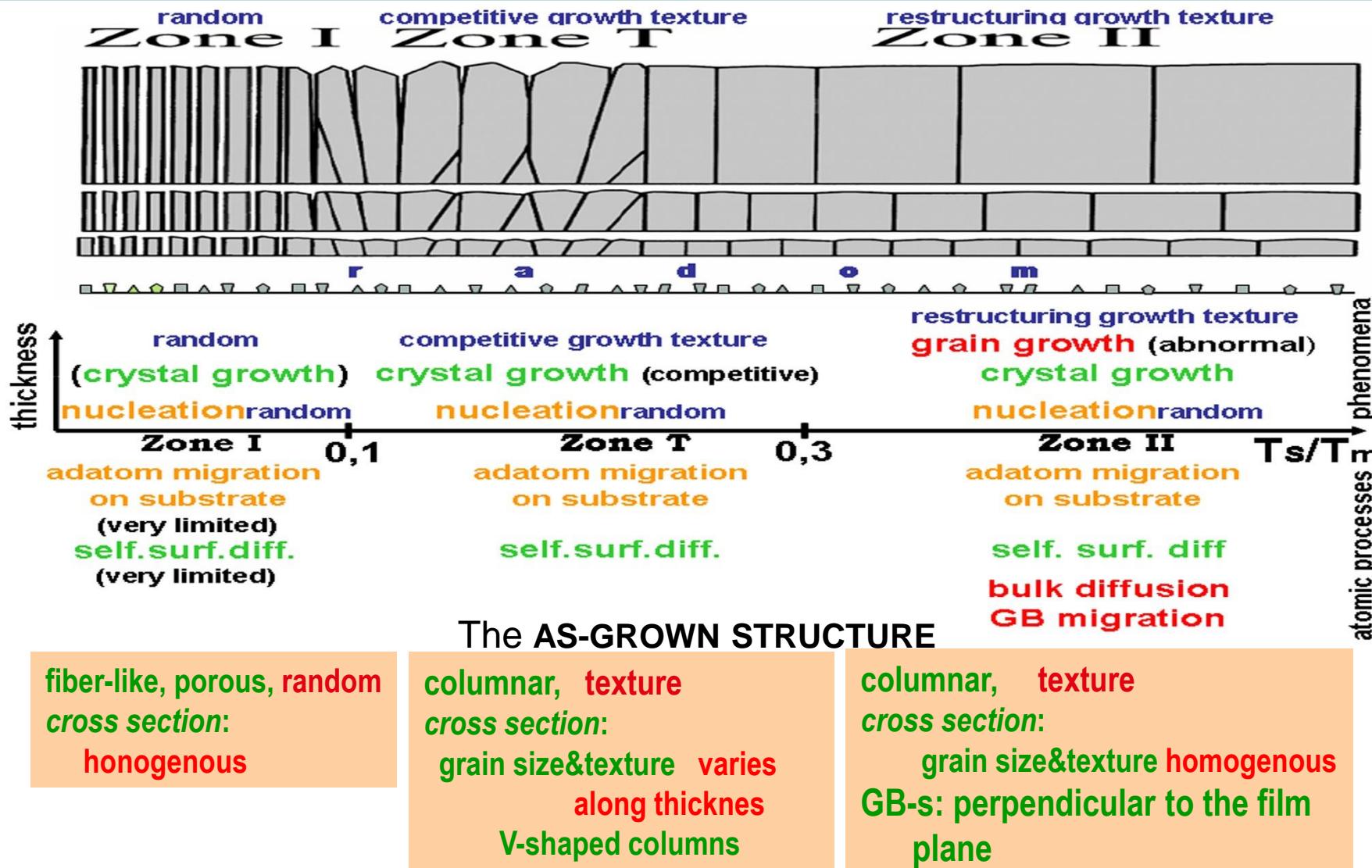
**0,3 nm/s**

**0,2 μm**

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# The STRUCTURE ZONE MODEL of elemental thin films growing on amorphous substrate



I.Petrov, P.B.Barna, L.Hultman, J.E.Greene: *J.Vac.Sci.Technol. A 21(5) (2003) S117*

P.B.Barna, G. Radnóczki, *Structure formation during deposition of polycrystalline metallic films*, in K. Barmak&K. Coffey (Ed), *Metallic films for electronic, optical and magnetic properties*, Woodhead Publishing Series in Electronic and Optical Materials, Nr. 40 (2014)67-120

**We are grateful and indebted to late  
Professor J. F. Pócza,  
who was our mentor, who initiated and supervised  
the systematic study of the structure evolution in  
thin films by proposing the application of in situ  
UHV transmission electron microscopy  
experiments and by introducing a new synthetic  
view for the evaluation and interpretation of the  
results in their complexity.**

# **Publications discussing results of in situ UHV transmission electron microscopic thin film experiments**

**Department of Thin Films, Research Institute for Technical Physics and Materials Science, Centre for Energy Research,  
Hungarian Academy of Sciences,  
1525 Budapest, P.O.Box 49, Hungary**

- E.F.Pócza, Á.Barna, P.Barna: Nucleation and growth processes in vacuum deposited Ge films,  
Proc. Int. Symp. Basic Problems of Thin Film Physics, Clausthal-Göttingen, (1966) p. 153-156
- Á.Barna, P.B.Barna, J.F.Pócza: The investigation of the growth-process of thin films by electron microscope,  
Proc.Czechoslovak Summer School on Thin Films, Ledec, 1967, 71-126
- Á.Barna, P.B.Barna, J.F.Pócza: Process of "liquid-like behaviour" of crystallites in vacuum deposited thin films,  
Roszt Krisztallow 8, (1968) 124-139,
- Á.Barna, P.B.Barna, J.F.Pócza: Process of "liquid-like behaviour" of crystallites in vacuum deposited thin films,  
Growth of Crystals 8, (1969) 124-130
- Á.Barna, P.B.Barna, J.F.Pócza: Design of a new vacuum deposition specimen holder for an electron microscope operating at  $10^{-7}$  torr,  
Vacuum, 17, (1967) 219-221
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